

# Si 99.999% 10-30mm 500g - 0481799

## Specifications

Coating material	Silicon
Purity	99.999%
Form	Granulate
Dimensions	10 - 30 mm
Quantity	500 g
Theoretical density at 20°C in g/cm <sup>3</sup>	2.3
Melting point in °C	1410

## Temperature at vapor pressure

10 <sup>-2</sup> mbar in °C	1630
10 <sup>-1</sup> mbar in °C	1830
Boiling point in °C	2355

## Type of evaporation

Melting	Good
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## Evaporation source (typically)

### E-gun

Directly from Cu crucible	Good
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### Boat

#### Boat material

W	Possible
Mo	Good

## Specific evaporation conditions

Preparation of base melt (pre-melt)	Good
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Low residual pressure	Good
Reactive gas pressure	Possible

## Substrate temperature range

100 - 200 °C	Good
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## Film transparency

Low	1
High	8

## Film refractive index n / extinction coefficient k

at 550 nm: n	3.9(1 μm)
at 10 μm: k	3.4(3 μm)